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DOCUMENT(S) FAXED: (MARKED WITH X) 20 PAGES ATTACHED

Re Applic of	Edward Barth, et al.
Docket No.	FIS9-1999-0263US2
Serial No.	10/659,778
Filing Date	09/10/03
Attorney	LISA J. ULRICH

Document(s) Attached: AMENDMENT, AMENDMENT TRANSMITTAL LETTER, SIGNED
DECLARATION, AUTHORIZATION TO ACT IN A REPRESENTATIVE CAPACITY, DRAWINGS (2)

PLEASE DELIVER TO:

EXAMINER: NOVACEK, CHRISTY L.
ART UNIT: 2822
PHONE NO: 571- 272-1839
FAX NO: 703-872-9306

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2070 Route 52
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New York 12533-6531

Fax: 845-892-6363
Phone: 845-894-3338

AMENDMENT TRANSMITTAL LETTER (Large Entity)			Docket No. FIS919990263US2
Applicant(s): Edward Barth, et al.			
Serial No. 10/659,778	Filing Date 9/10/03	Examiner Novacek, Christy L.	Group Art Unit 2822

Invention: Dual-Damascene Interconnect Structure Using Low Stress
Stress Fluorosilicate Insulator with Copper Conductors

TO THE COMMISSIONER FOR PATENTS:

Transmitted herewith is an amendment in the above-identified application.

The fee has been calculated and is transmitted as shown below.

CLAIMS AS AMENDED

	CLAIMS REMAINING AFTER AMENDMENT	HIGHEST # PREV. PAID FOR	NUMBER EXTRA CLAIMS PRESENT	RATE	ADDITIONAL FEE
TOTAL CLAIMS	8	8	0	x \$18.00	\$0.00
INDEP. CLAIMS	1	1	0	x \$86.00	\$0.00
Multiple Dependent Claims (check if applicable) <input type="checkbox"/>					\$0.00
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT					\$0.00

- ☒ No additional fee is required for amendment.
- ☐ Please charge Deposit Account No. _____ in the amount of _____
- ☐ A check in the amount of _____ to cover the filing fee is enclosed.
- ☒ The Director is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account No. 090458
- ☒ Any additional filing fees required under 37 C.F.R. 1.16.
- ☒ Any patent application processing fees under 37 CFR 1.17.

Lisa J. Ulrich
Signature

Dated: 6/29/04

LISA J. ULRICH, REG. NO. 45,168
2070 ROUTE 52
HOPEWELL JUNCTION, NY 12533

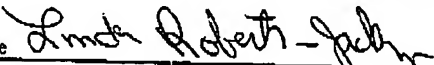
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10/659,778

FIS919990263US2

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In the United States Patent and Trademark Office

Date:	6/29/04	
In re Application of:	Edward Barth, et al.	Filed: 9/10/03
For:	Dual-Damascene Interconnect Structure Using Low Stress Fluorosilicate Insulator with Copper Conductors	
Serial Number:	10/659,778	
Art Unit:	2822	Examiner: Novacek, Christy L.

AMENDMENT

Hon. Commissioner of Patents and Trademarks
P. O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action dated March 29, 2004, Applicants submit the following amendments and remarks: